

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Jarmo Ilmari Maula et al.

Confirmation No. 6735

Application No. 10/609,136

Filed: June 26, 2003

For: **DIAPHRAGM VALVE FOR HIGH-
TEMPERATURE PRECURSOR
SUPPLY IN ATOMIC LAYER
DEPOSITION**

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Group Art Unit: 3753

Examiner: Kevin L. Lee

Date: December 6, 2004

AMENDMENT

TO THE COMMISSIONER FOR PATENTS:

In response to the September 3, 2004 Office action, please amend the above-identified patent application as follows.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims that begins on page 3 of this paper.

Remarks begin on page 12 of this paper.